

Notice of References Cited		Application/Control No. 10/584,409	Applicant(s)/Patent Under Reexamination YOON ET AL.	
		Examiner MARTIN ANGEBRANNNDT	Art Unit 1722	Page 1 of 1

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	U	Chang et al., "Shape controlled, high fill factor microlens arrays fabricated by a 3d diffuser lithography and plastic replication method", Opt. Exp. Vol. 12(25) pp 6366-6371 (12/2004)
	V	machine translation of JP 2000-241607, 12 pages (2000)
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.